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# On the stability of the Higher Manganese Silicides

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## ABSTRACT

We investigated in this work the stability of the Higher Manganese Silicides (HMS). Several alloys in the composition range 62–66 at.% Si were prepared from their constitutive elements by arc-melting. The prepared alloys were then analysed by in situ X-ray diffraction measurements and Electron Probe Micro-Analyser (EPMA). The whole results allow us to suggest that whatever the composition is, only  $Mn_{27}Si_{47}$  is stable for the temperatures 500 °C and 800 °C. At higher temperatures, the studied samples undergo two phase transformations which consecutively lead to the formation of  $Mn_{15}Si_{26}$  and  $Mn_{11}Si_{19}$ .  $Mn_4Si_7$  was never evidenced in the present work. It is shown for the first time in this work that  $Mn_{27}Si_{47}$  is the only HMS stable phase at room temperature.

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#### 1. Introduction

The semiconductors Higher Manganese Silicides  $MnSi_x$  (x = 1.72–1.75) also known as HMS are the highest siliconrich intermediate phases in the manganese–silicon binary phase diagram. These compounds have attracted much attention in recent years because of their applications in spintronics, such as ferromagnetic semiconductors, and in thermoelectrics due to their large Seebeck coefficient, low resistivity, and high oxidation resistance [1–3]. Besides, they are non-toxic and cheap.

In previous studies, HMS has been successfully synthesized using different methods: solid phase reaction, sputtering, reactive deposition epitaxy, and chemical reaction [4–7]. However, there are some disagreements in the reported physical properties of HMS [8], and it was suggested that these discrepancies come from the subtle structural differences in the complex crystal structures of HMS [6]. Four HMS Mn<sub>4</sub>Si<sub>7</sub> [9], Mn<sub>11</sub>Si<sub>19</sub> [10], Mn<sub>15</sub>Si<sub>26</sub> [11], and Mn<sub>27</sub>Si<sub>47</sub> [12] are reported in literature. These phases are referred to as the "Nowotny chimney ladder" phase being derived from a TiSi<sub>2</sub> parent structure [13]. They all possess a tetragonal unit cell with high anisotropy. The 'a' lattice parameter is the same for all the structures since the 'c' one is different. These structures consist in "chimney" Si and "ladder" Mn sublattices.

To optimize physical properties of HMS for applications, knowledge on the crystal structure, the composition, and the phase stability of HMS is required. The stability range of these HMS phases has not been determined so far. The Mn–Si phase diagram reports a homogeneity range around  $MnSi_{1.75}$  [14] without giving information on these different structures. Therefore the aim of this work was to investigate the stability range of the HMS phases.

We prepared several alloys in the composition range 62–66 at.% Si, from their constitutive elements by arc-melting and we studied their stability range in temperature by using X-ray diffraction measurements and Electron Probe Micro-Analyser (EPMA).

#### 2. Experimental details

The  $Mn_xSi_y$  alloys were synthesized from their constitutive elements, Mn (99.8%) and Si (99.999%), by arc melting in a water-cooled copper crucible under argon (99.995%). Mn and Si elements were weighed in different atomic percentages. The compositions of the prepared alloys are as follows:  $Mn_{38}Si_{62}$ ,  $Mn_{37}Si_{63}$ ,  $Mn_{36}Si_{64}$ ,  $Mn_{35}Si_{65}$ , and  $Mn_{34}Si_{66}$ . Three melting steps were carried out for each alloy in order to produce chemically homogeneous samples. After arc melting all the ingots were encapsulated in quartz tubes under argon, heat-treated at 500 °C and 800 °C for 2 weeks and 1 week, respectively and then quenched in water at room temperature. These annealings were performed in order to reach the equilibrium state.

The X-ray diffraction patterns were recorded on a Philips X'pert system using the Cu K\alpha radiation with the Bragg–Brentano geometry and an Xcelerator X-ray detector. Two different kinds of XRD analysis were carried out: analysis at room temperature, and in situ analysis. For in situ high temperature (HT) XRD measurements, the samples were loaded into an XRD chamber, equipped with a heating stage in a vacuum of about  $10^{-5}$  mbar. The XRD measurements were performed each  $20\,^\circ$ C from 100 to  $1000\,^\circ$ C. The heating rate was  $5\,^\circ$ C/min. The diffractograms were recorded in the [20–60 $^\circ$ ]  $2\theta$  range, with a step size of 0.02 $^\circ$  and a step time of 10 s.

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Fig. 1. XRD patterns recorded at room temperature for samples annealed at 500  $^\circ\text{C}$  for 2 weeks.



Fig. 2. XRD patterns recorded at room temperature for samples annealed at 800  $^\circ\text{C}$  for 1 week.

Electron Probe Micro-Analyser (EPMA, CAMECA SX100) was used in the following conditions: U = 20 kV and I = 4 nA.

#### 3. Results and discussion

#### 3.1. XRD diffraction at room temperature

Figs. 1 and 2 show the XRD patterns recorded at room temperature on samples annealed at 500  $^{\circ}$ C for 2 weeks, and at 800  $^{\circ}$ C for 1 week, respectively.

#### Table 1

Chemical compositions obtained by EPMA analysis on samples  $Mn_{34}Si_{66}$  and  $Mn_{38}Si_{62}$  annealed at 800  $^\circ\text{C}.$ 

	$Mn_{34}Si_{66}(a)$	Mn <sub>38</sub> Si <sub>62</sub> (b)
Dark phase	97.97% Si	63.11% Si
	2.02% Mn	36.88% Mn
Light phase	63.14% Si	50.35% Si
	36.85% Mn	49.64% Mn

The analysis of Fig. 1 shows that the samples  $Mn_{38}Si_{62}$ ,  $Mn_{37}Si_{63}$ and  $Mn_{36}Si_{64}$  contain ( $MnSi + Mn_{27}Si_{47}$ ). We can notice that the intensity of the MnSi peaks decreases with the increase of the silicon content. For the samples  $Mn_{35}Si_{65}$  and  $Mn_{34}Si_{66}$ , they are constituted of ( $Si + Mn_{27}Si_{47}$ ), and the intensity of the Si peaks increases with the Si atomic percentage.

Therefore whatever the composition, the HMS present in the samples annealed at 500 °C is  $Mn_{27}Si_{47}$ . The same conclusion can be deduced from Fig. 2 for samples annealed at 800 °C.

Our samples can be classified into two groups of composition: one containing MnSi and  $Mn_{27}Si_{47}$ , the other containing  $Mn_{27}Si_{47}$  and Si and  $Mn_{27}Si_{47}$  is the only HMS phase present in samples annealed both at 500 and 800 °C.

#### 3.2. EPMA analysis

We analysed by EPMA all the samples that we prepared, however since these samples can be classified into two groups of compositions, and in sake of clarity, we only present in this article the results obtained for the end member alloys Mn<sub>38</sub>Si<sub>62</sub> and Mn<sub>34</sub>Si<sub>66</sub> annealed at 800 °C. The results are presented in Fig. 3a and b for Mn<sub>38</sub>Si<sub>62</sub> and Mn<sub>34</sub>Si<sub>66</sub>, respectively. Both samples are constituted of two phases. The chemical compositions of these phases are given in Table 1. In agreement with the X-ray diffraction results, Mn<sub>38</sub>Si<sub>62</sub> contains (MnSi+HMS) and Mn<sub>34</sub>Si<sub>66</sub> is constituted of (HMS + Si). The composition of the HMS is approximately the same in both samples (63.15 at.% Si and 36.85 at.% Mn). These results support the X-ray diffraction results; only one HMS is stable at 800 °C. Since the accuracy of the EPMA analysis is around 0.5 at.% and the reliability of X-ray diffraction measurements is high, we can suggest based on XRD results that the stable HMS is Mn<sub>27</sub>S<sub>47</sub>.

#### 3.3. In situ XRD

As for the EPMA analysis, we investigated all the samples by using in situ X-ray diffraction measurements but we only show in this paper the results obtained for the end-member alloys  $(Mn_{34}Si_{66} \text{ and } Mn_{38}Si_{62})$  annealed at 800 °C. The XRD patterns of  $Mn_{34}Si_{66}$  and  $Mn_{38}Si_{62}$  are presented in Figs. 4 and 5, respectively.



Fig. 3. EPMA micrographs of samples annealed at 800  $^\circ C$  (a)  $Mn_{34}Si_{66}$  and (b)  $Mn_{38}Si_{62}$ 

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